

# United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS Washington, D.C. 20231 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/052,538	01/23/2002	Tetsunori Kaji	520.35237VX3	4015
20457	7590 10/03/2002			
ANTONELLI TERRY STOUT AND KRAUS SUITE 1800 1300 NORTH SEVENTEENTH STREET			EXAMINER	
			DANG, THI D	
ARLINGTO	N, VA 22209	ART UNIT PAPER NUMBER		PAPER NUMBER
			1763	71
			DATE MAILED: 10/03/2002	9

Please find below and/or attached an Office communication concerning this application or proceeding.

PTO-90C (Rev. 07-01)

		hw-3				
,	Application No.	Applicant(s)				
"O SEE O O O O	10/052,538	KAJI ET AL.				
Office Action Summary	Examiner	Art Unit				
	Thi Dang	1763				
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period was a failure to reply within the set or extended period for reply will, by statute, any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).  Status	36(a). In no event, however, may a reply be ting within the statutory minimum of thirty (30) day vill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133)				
1) Responsive to communication(s) filed on	<u> </u>					
2a) This action is <b>FINAL</b> . 2b) ⊠ Thi	is action is non-final.					
3) Since this application is in condition for allowa						
closed in accordance with the practice under <i>l</i> <b>Disposition of Claims</b>	Ex parte Quayle, 1955 C.D. 11, 4	103 U.G. 213.				
4)⊠ Claim(s) 14-18 and 23-27 is/are pending in the application.						
4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>14-18 and 23-27</u> is/are rejected.						
7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/or	election requirement.					
Application Papers						
9) The specification is objected to by the Examiner.						
10)⊠ The drawing(s) filed on <u>23 January 2002</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner.						
If approved, corrected drawings are required in reply to this Office action.						
12) ☐ The oath or declaration is objected to by the Examiner.						
Priority under 35 U.S.C. §§ 119 and 120						
13)⊠ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a)⊠ All b)□ Some * c)□ None of:		, , , ,				
1. Certified copies of the priority documents	s have been received.					
2. Certified copies of the priority documents	s have been received in Applicati	on No. <u>08/808,805</u> .				
<ul> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>						
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).						
a) ☐ The translation of the foreign language pro-	visional application has been rec	eived.				
Attachment(s)	. ,					
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of Informal F	(PTO-413) Paper No(s) Patent Application (PTO-152)				

Application/Control Number: 10/052,538

Art Unit: 1763

### Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

(e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371(c) of this title before the invention thereof by the applicant for patent.

The changes made to 35 U.S.C. 102(e) by the American Inventors Protection Act of 1999 (AIPA) do not apply to the examination of this application as the application being examined was not (1) filed on or after November 29, 2000, or (2) voluntarily published under 35 U.S.C. 122(b). Therefore, this application is examined under 35 U.S.C. 102(e) prior to the amendment by the AIPA (pre-AIPA 35 U.S.C. 102(e)).

2. Claims 14-16 are rejected under 35 U.S.C. 102(e) as being anticipated by *Arai* et al.

Arai discloses a plasma processing apparatus, which includes: a pair of electrodes for generating plasma; a high frequency power source for generating plasma that is capable of applying a voltage of 13.56 MHz or 40 MHz (i.e., within the range of 10 MHz – 500 MHz); and means for applying a pulse bias to the substrate-holding electrode (col. 4, lines 5-27; Figs. 1 and 18). The power supply system of Arai also has means for preventing voltage charge-up (col. 6, lines 36-65). Arai also discloses that an electrostatic chuck (31) may be used for holding the substrate (Fig. 1). The apparatus disclosed by Arai meets the structural limitations of the claimed apparatus.

Application/Control Number: 10/052,538

Art Unit: 1763

### Claim Rejections - 35 USC § 103

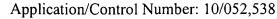
- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claims 17 and 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over *Arai* et al in view of *Ogasawara* et al.

Arai does not disclose a gap of 10 mm to 50 mm between the parallel electrodes.

Ogasawara teaches that it is conventional in the art to have an electrode gap of 10 mm to 20 mm during etching (col. 12, lines 57-58). It would have been obvious to have a gap of 10 mm to 20 mm between the electrodes in Arai's apparatus during etching because it is conventional in the art.

5. Claims 23-27 are rejected under 35 U.S.C. 103(a) as being unpatentable over *Kadomura* in view of *Kofuji* et al.

Kadomura discloses a plasma processing apparatus, which includes: a section (21) for generating an uptream plasma and supplying radicals to the processing chamber; means (31) for generating plasma in the processing chamber; a bias supplying means (41) connected to the wafer holder. The apparatus of Kadomura has all of the claimed structures recited in claim 23 except an electrostatic attracting means. Kofuji teaches that it is conventional in the art to place an electrostatic chuck on the wafer holder in order to hold the wafer by electrostatic attracting force. Therefore, it would have been obvious to provide an electrostatic chuck on the wafer holder of Kadomura because it is conventional to hold a wafer by electrostatic attracting force.



Art Unit: 1763

Kofuji also teaches to provide means for applying a pulse bias to the wafer in order to eliminate electron shading during plasma processing (col. 2, lines 13-28). It would have been obvious to provide Kofuji's system of applying a pulse bias in Kadomura because this modification would eliminate electron shading during plasma processing.

# Claim Objections

6. Claim 18 is objected to under 37 CFR 1.75(c), as being of improper dependent form for failing to further limit the subject matter of a previous claim. Applicant is required to cancel the claim(s), or amend the claim(s) to place the claim(s) in proper dependent form, or rewrite the claim(s) in independent form. Claim 18 is dependent on either claim 16 or 17. However, the limitation recited in claim 18 already exists in claim 16.

#### Conclusion

- 7. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. *Gorin, Corn* et al, *Tsai* et al, *Doki* et al, *Collins* et al are cited to show other plasma processing apparatus.
- 8. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Thi Dang whose telephone number is (703) 308-1973. The examiner can normally be reached on Monday to Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Gregory Mills can be reached on (703) 308-1633. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 872-9310 for regular communications and (703) 872-9311 for After Final communications.

Application/Control Number: 10/052,538

Art Unit: 1763

538 Page 5

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0661.

EXAMPLE TO